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(54) Titre : PART HAVING A DLC COATING AND METHOD FOR APPLYING THE DLC COATING

(54) Titre : PIÈCE AVEC REVETEMENT DLC ET PROCÉDE D'APPLICATION DU REVETEMENT DLC

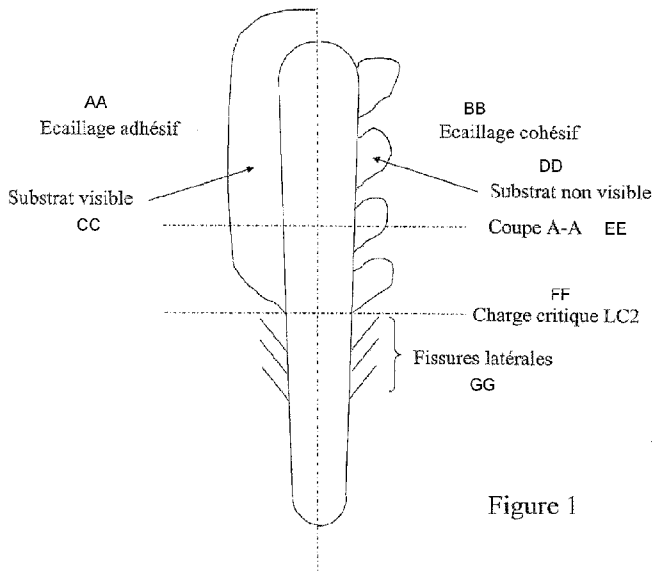


Figure 1

(57) Abstract : The invention relates to a part having a layer with a WC-C composition gradient, with the exception of a metal sub-layer and with the exception of an ion implantation layer and a surface layer of DLC, wherein said part is characterized by having cohesive behaviour in a scratch test.

(57) Abrégé : Cette pièce présente une couche à gradient de composition WC-C, à l'exception d'une sous-couche métallique et à l'exception d'une couche d'implantation ionique et une couche superficielle de DLC, caractérisée par un comportement cohésif en scratch test.

AA Adhesive flaking  
BB Cohesive flaking  
CC Visible substrate  
DD Non-visible substrate  
EE Cross-section A-A  
FF Critical load LC2  
GG Side cracks

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**PART WITH DLC COATING AND METHOD FOR APPLYING THE**  
**DLC COATING**

5 The invention relates to the technical field of DLC (Diamond-Like Carbon) coatings, especially those for friction parts.

10 The invention has an especially advantageous application in reducing the coefficient of friction, of piston rods, camshafts, valve lifters, cylinders, piston rings etc. for example and, more generally, in all cases of friction under load. In order to reduce such friction, those skilled in the art are perfectly aware of the possibility of applying a DLC coating to the part or parts in question.

15 The invention may also have applications where there is a requirement for the surface provided by the coating to have a black colour without this involving any attempt to reduce friction.

20 It is also generally known by those skilled in the art that the low adhesion of DLC films on components is capable of posing real problems in certain applications. One technical solution in order to improve adhesion involves using a metal-containing adhesive layer based on silicon or chromium for instance. Various technical solutions have been proposed.

25 Document WO2011/018252, for example, describes a friction part having a coating consisting of an adhesive layer, a metal-containing DLC coating and a metal-free DLC coating. The adhesive layer is preferably a chromium coating having a maximum thickness of 1  $\mu\text{m}$  whereas the metal-containing DLC coating is preferably made of WCC tungsten carbide. The ratios of the thicknesses of the various layers and coatings are limited to certain ranges of values so that, outside these ranges, if the DLC thickness is too small, the service life of the component will be shortened and if the DLC

thickness is too large, the component will wear prematurely with risks of peeling or flaking off.

5 Document WO0179585 discloses a multilayer system having an adhesive layer, a transition layer and a layer of diamond-like carbon. The adhesive layer comprises an element in the 4th, 5th or 6th subgroup and silicon whereas the transition layer comprises carbon and at least one element in the 4th, 5th or 6th subgroup and silicon. The upper layer is predominantly made of diamond-like carbon. The system has a hardness of at least 15 GPa and an adhesive strength of at least HF3.

10

Generally speaking, delamination of the DLC film from this undercoat associated with internal stresses in the DLC film is observed and this delamination increases the thicker such a film is. It is also apparent that this adhesive undercoat is formed in a separate step and that this increases the cost of the method and makes such a method more complicated.

15

The invention has set itself the object of overcoming these drawbacks in a simple, dependable, effective and efficient manner.

20

The problem which the invention intends to solve is to produce DLC films having improved adherence without using a metal-containing adhesive undercoat (e.g. silicon or chromium) based on the teaching of the prior art.

25 In order to solve such a problem, a metal part having a layer with a WC-C composition gradient, with the exception of a metal-containing undercoat, and a DLC surface layer characterised by cohesive behaviour in scratch tests has been designed and perfected.

The stated problem is advantageously solved by a method in which one:

- microwave etches the part;
- subjects the part to a WC-C composition gradient layer;
- 5 - uses a microwave plasma to apply the DLC coating to the WC-C layer;

Microwave etching makes it possible to obtain more effective etching (regardless of the geometry of the part that is to be treated) than is possible using diode etching by adjusting the flow of ions. It is also possible to etch  
10 parts at a low tempering temperature without degrading them. It is also observed that using a microwave DLC coating makes it possible to reduce the application process time by roughly 50% compared with a conventional DLC coating.

15 Advantageously, one creates an argon plasma in order to obtain etching over a pressure range from 0.05 to 0.5 Pa.

According to another aspect, one produces the WC-C composition gradient layer by using a magnetron PVD technique. One starts with a first  
20 pure WC layer followed by a ramp with a hydrocarbon gas such as  $C_2H_2$  followed finally by a WC-C layer. The thickness of the WC-C composition gradient layer is 0.3 to 10  $\mu m$  and advantageously 0.8  $\mu m$  for most applications, apart from those that require bigger thicknesses such as piston rings

25 According to another aspect, the DLC coating has a thickness of 1 to 20  $\mu m$ .

The invention also relates to a friction part having a DLC coating applied to a WC-C composition gradient layer which the microwave-etched part has.

The invention is explained below in greater detail, reference being made to the accompanying drawings in which:

- 5 - Figure 1 is a view of the fracture profile of the coating using the scratch test method.
- Figure 2 is a cross-sectional view along line A-A in Figure 1 in the case of adhesive flaking.
- Figure 3 is a cross-sectional view along line A-A in Figure 1 in the case of cohesive flaking. Figure 4 is a cross-sectional view along line A-A in  
10 Figure 1 in the case of cohesive/adhesive flaking.

As indicated, the prior art describes DLC coatings that include, in every case, an adhesive undercoat made of pure Cr, for example, followed by a tungsten carbide-based layer in which the carbon content is gradually  
15 increased until a tungsten-doped DLC layer is obtained with the objective of ensuring the adhesion of deposited DLC that is not doped with metal.

In the context of the invention, tests have been performed in order to compare the results obtained by producing DLC coatings with one or more  
20 adhesive undercoats and a DLC coating that does not use an adhesive layer in accordance with the aspects of the invention.

Materials were deposited on metal-containing substrates that had previously been ion etched in order to eliminate any superficial oxide so as to  
25 improve adhesion of the coating. Various ion etching technologies are familiar to those skilled in the art, namely, mainly, diode etching, triode plasma etching and ECR microwave etching.

Diode etching involves applying a negative voltage of several hundred volts (<-500V) to the substrates in an argon atmosphere at a pressure of 1 to 10 Pa. Under these conditions, there is a luminous discharge around the parts and positive argon ions in the plasma bombard the surface of the substrate allowing surface sputtering and the elimination of oxide.

Using triode plasma technology, a dense argon plasma at a lower pressure (0.1 to 1 Pa) is produced by a plasma amplifier. The positive argon ions are accelerated by negatively biasing the substrate and they etch the surface. For this type of method, the negative voltage must be between -250 V and -500 V in order to achieve maximum etching efficiency.

ECR microwave etching makes it possible to produce an argon plasma over a pressure range of 0.05 to 0.5 Pa. The parts are biased by a negative voltage which is optimally -50 V to -250 V.

Each of these etching technologies was used for these tests. Following etching, a pure chromium adhesive undercoat was produced on some of the test pieces by magnetron cathode sputtering in order to obtain a chromium thickness of approximately 0.1 to 0.2  $\mu\text{m}$ . Tungsten carbide was then deposited on all the test pieces by magnetron cathode sputtering, gradually increasing the hydrocarbon flow rate making it possible to enrich the deposited carbon to an atomic concentration in excess of 50% in order to enable adhesion of the final DLC coating. The tungsten-containing layer had a thickness of approximately 0.5  $\mu\text{m}$  and the DLC was approximately 2  $\mu\text{m}$  thick, apart from examples 9 and 10 where the thickness of the tungsten-containing layer was increased to 1.5  $\mu\text{m}$ .

The following table summarises the test conditions.

Etching technology	Presence of a Cr adhesive layer
Diode	Yes
Diode	No
Triode	Yes
Triode	No
ECR	Yes
ECR	No

All the coatings were characterised in terms of their adhesion. The scratch test method was used. The reader is reminded that this method involves scratching the surface of the deposited material with a diamond such as those used for the HRC indentation test. A gradually increasing load is applied while the test piece is translationally moved at constant speed underneath the diamond. This makes it possible to obtain an increasing-load scratch (Figure 1) on the basis of which it is possible to determine a flaking force (critical load) as well as the flaking mode. The flaking mode indicates the location of the break in the coating. There are two main types of flaking:

- Adhesive flaking (Figure 2)
- Cohesive flaking (Figure 3)

There is a mixed mode which combines adhesive fracture with cohesive fracture which is referred to as cohesive/adhesive (Figure 4).

Adhesive flaking corresponds to the propagation of cracks along one interface and hence parallel to the surface of the part whereas cohesive flaking propagates through the coating at an oblique angle relative to the interfaces. Adhesive flaking characterises lack of adhesion of the coating. Cohesive flaking occurs when the stresses exceed the breaking limit (mechanical strength) of the materials that constitute the coating.

In the case of the adhesive facies, the critical load characterises the adhesion force.

In the case of a cohesive failure, it is the breaking strength of the coating that is characterised, not its adhesion. The critical load is not only a characteristic of the deposited material, it is also a characteristic of its thickness and the hardness of the substrate.

5 A second method was used to evaluate adhesion. It involves indenting the deposited material by using a Vickers diamond under a load of 2 kg.

10 The table below summarises the series of experiments including the results of the scratch test obtained on substrates made of tool steel (hardness 64 HRC) for total deposited thicknesses of 2.5  $\mu\text{m}$  without a chromium undercoat and 2.7  $\mu\text{m}$  with a chromium undercoat and a total thickness of 3.5  $\mu\text{m}$  in the case of examples 9 and 10. Examples 11 and 12 have thick stacks which demonstrate the robustness of the invention. Example 11  
15 comprises a 4  $\mu\text{m}$  thick tungsten-based layer on which an 8  $\mu\text{m}$  thick DLC had been deposited. In the case of example 12, the thickness of the tungsten layer was increased to 9.7  $\mu\text{m}$  and that of the DLC surface layer was increased to 19.2  $\mu\text{m}$ .

Example	Etching technology	Presence of a Cr adhesive layer	Etching pressure in Pa	Critical load in N	Facies	Vickers indentation with 2 kg (20 N)
1.	Diode	Yes	2	32	C	NTR
2.	Diode	No	2	6	A	NTR
3.	Triode	Yes	0.6	33	C	NTR
4.	Triode	No	0,6	8	A	NTR
5.	Triode	No	0.4	18	CA	NTR
6.	ECR	Yes	0.5	32	C	NTR
7.	ECR	No	0.5	18	CA	NTR
8.	ECR	No	0.3	31	C	NTR
9.	ECR	No	0.3	36	C	NTR
10.	ECR	No	0.3	35	C	NTR
11.	ECR	No	0.3	44	C	NTR
12.	ECR	No	0.3	55	C	NTR

C = Cohesive

A = Adhesive

CA = Cohesive/adhesive

NTR = No detachment of deposited material

5

The above table shows that, in the case of diode etching and in accordance with the teaching of the prior art, the chromium undercoat makes it possible to obtain strong adhesion (example 1) and that, in its absence, failure occurs at the interface between the WC and the steel (example 2).

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Using triode etching technology results in a change in the behaviour of the deposited material when it is scratched without a chromium undercoat (examples 4 and 5). The critical load increased compared with diode etching (example 2) and the flaking mode changed (examples 4 and 5).

15

The observed flakes reveal an intermediate flaking mode.

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According to the invention, using ECR microwave etching technology demonstrates that it is possible to obtain mechanical behaviour that is quite similar to the prior art without a chromium undercoat (example 8). Note that, as with triode etching technology, reducing the pressure results in improved scratch test performance (examples 7 and 8).

25

Examples 9 and 10 show that resistance to cohesive flaking is increased by the thickness of the tungsten-containing undercoat, as demonstrated by the critical load values. In the two examples, the thickness of the tungsten carbide and the gradient layer is 1.5  $\mu\text{m}$ . More especially, in example 9, the tungsten-carbide thickness was increased to 1  $\mu\text{m}$ , the thickness which corresponds to the carbon concentration gradient is 0.5  $\mu\text{m}$ .

In example 10, the tungsten-carbide thickness is 0.2  $\mu\text{m}$ , whereas the carbon concentration gradient layer is increased to 1.3  $\mu\text{m}$ .

Examples 11 and 12 illustrate the robustness of the solution. It is known that increasing the thickness of thin hard layers deposited in a vacuum results in an increase in their internal compression stresses. Nevertheless, behaviour during the scratch test remains cohesive and the increase in the critical load is the result of increasing the thickness of the tungsten-based layer.

Over and above the etching technology, the results tend to show an improvement in the adhesion of the layers produced without a chromium undercoat when the etching pressure is diminished. The pressure reduction during etching depends on the actual technology itself. Diode technology is typically incapable of generating plasma pressures as low as 0.5 Pa.

Thus, according to the invention, using an appropriate etching technology makes it possible to reduce the argon pressure and produce a DLC type adhering stack without a chromium undercoat - an achievement that flies in the face of everything that is widely held by those skilled in the art and previous technical solutions.

The method according to the invention has numerous advantages:

Besides simplifying the equipment needed and reducing its cost, eliminating the adhesive undercoat also eliminates one interface and therefore improves the reliability and robustness of the coating.

It is also apparent, as revealed by the tests that were conducted, that the chromium undercoat tends to mask deficiencies in certain types of etching, in contrast to tungsten carbide which appears to require more

effective etching, in order to perform as well in terms of adhesion, as a material that is deposited with a chromium undercoat.

Also, using Vickers indentation with a 2 kg load did not make it possible to reveal any differences in the adhesion of various types of deposited materials.

5 Although the applied load was 2 kg (20 N), the deformation caused by the Vickers diamond was insufficient to cause detachment of the deposited materials, as in example 2, where adhesion has nevertheless been proven deficient by the scratch test method.

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## CLAIMS

- 2012257680 07 Jan 2014
- 5 1. Metal part having a layer with a WC-C composition gradient, with the exception of a metal-containing undercoat and with the exception of an ion implantation layer and a DLC surface layer characterised by cohesive behaviour in scratch tests.
- 10 2. Part as claimed in claim 1 covered in a DLC coating applied to a WC-C composition gradient layer which the part that has been microwave etched has.
- 15 3. Method for applying a DLC coating to a metal part characterised by the following steps:  
- One microwave etches the part,  
- One subjects the part to a WC-C composition gradient layer,  
- One uses a microwave plasma to apply the DLC coating to the WC-C layer.
- 20 4. Method as claimed in claim 3, characterised in that one generates an argon plasma in order to etch over a pressure range of 0.05 to 0.5 Pa.
- 25 5. Method as claimed in claim 3, characterised in that the WC-C composition gradient layer is produced by magnetron PVD.
6. Method as claimed in claim 5, characterised in that one starts with a first pure WC layer followed by a hydrocarbon flow rate ramp finally followed by a WC-C layer.

7. Method as claimed in either claim 5 or 6, characterised in that the thickness of the WC-C composition gradient layer is 0.3 to 10  $\mu\text{m}$  and advantageously 0.8  $\mu\text{m}$ .

5 8. Method as claimed in claim 3, characterised in that the DLC coating has a thickness of 1 to 20  $\mu\text{m}$ .

9. Part covered in a DLC coating obtained exclusively using the method as claimed in any of claims 3-8, characterised by the absence of a metal-containing undercoat and by the absence of an ion implantation layer and having a WC-C composition gradient.

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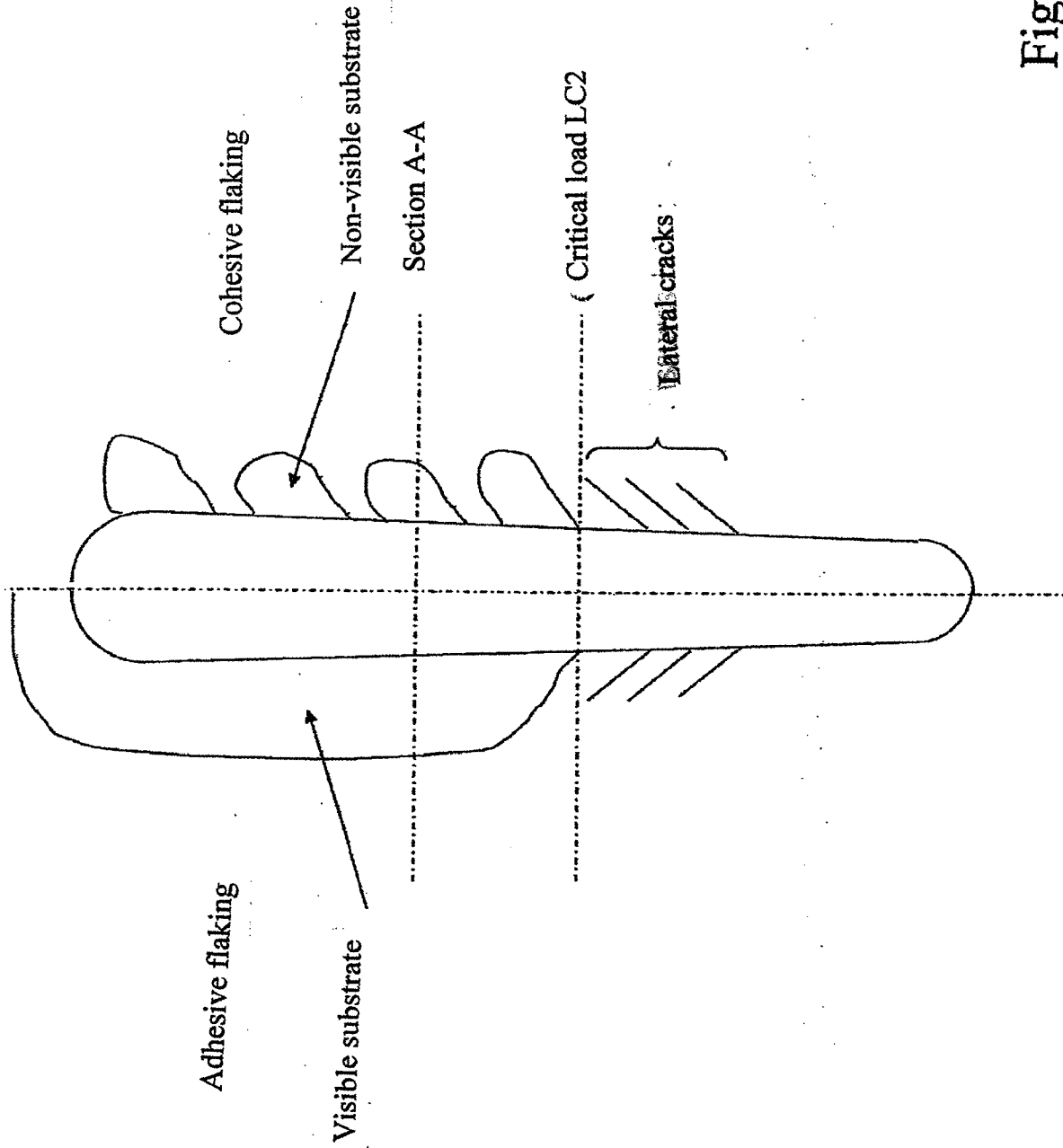
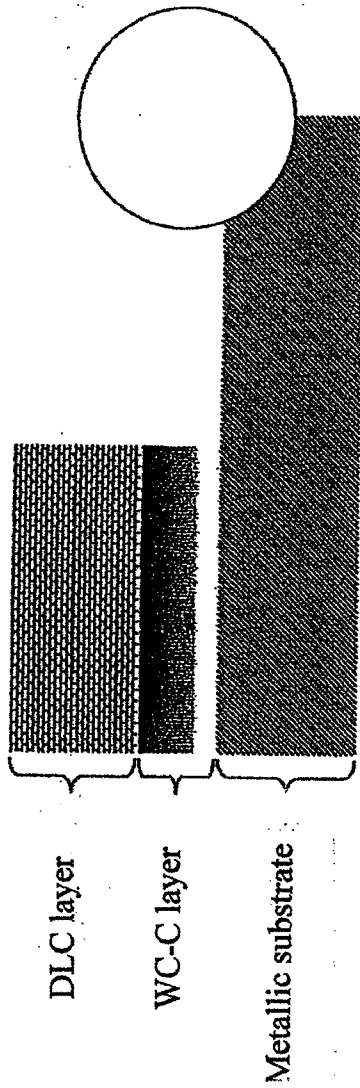


Figure 1

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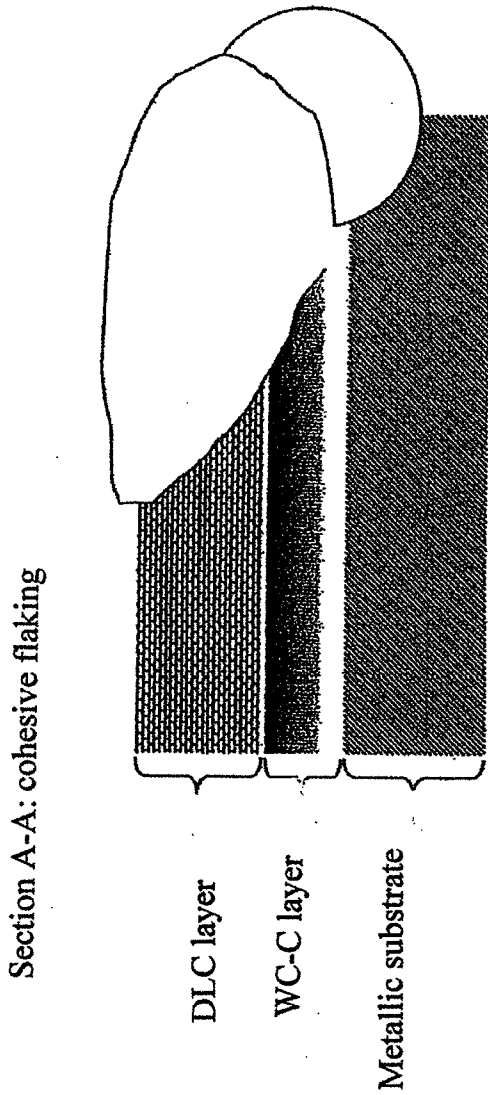
Figure 2

Section A-A: adhesive flaking



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B.

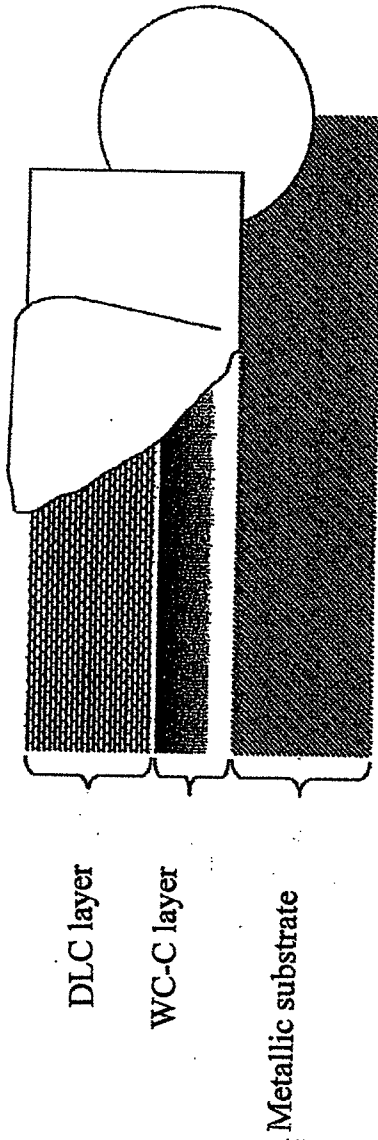
Figure 3



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Figure 4

Section A-A: cohesive/adhesive flaking



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